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This article [*Opt. Eng.* **44**, 103601 (2005)] was originally published on 4 October 2005 with three references missing from the reference list. These three references should be included in the reference list:

19. O. Zabeida and L. Martinu, "Ion energy distributions in pulsed large area microwave plasma," *J. Appl. Phys.*, **85**(9), 6366 (1999).

20. O. Zabeida et al., "Ion bombardment characteristics during the growth of optical films using a cold cathode ion source," *42nd Ann. Tech. Conf. Proc.*, Society of Vacuum Coaters, pp. 267–272 (1999).

21. D. E. Morton, "The effects of pumping speed on the operation of a cold cathode ion source," *43rd Ann. Tech. Conf. Proc.*, Society of Vacuum Coaters, pp. 207–211 (2000).

These additional references and the necessary callouts should have been located within the paper as detailed below.

Reference 19 should appear on p. 2, after the seventh sentence of Sec. 2.1 as follows:

Ion energy measurements were made using a versatile multi-grid retarding-field ion energy analyzer (IEA) for the

determination of ion energy distribution functions (IEDFs) in vacuum processing systems.¹⁹

Reference 20 should appear on p. 2, after the eighth sentence of Sec. 2.1 as follows:

This study was published previously²⁰ and discussed briefly here.

Reference 21 should be called out on p. 7, before the first sentence of the last paragraph of Sec. 4, and on p. 8, after the third and last sentences of the first paragraph of Sec. 5, and after the captions of Figs. 16 and 17, respectively, as follows:

The previous work on moisture stable stacks was achieved by D.E. Morton.²¹

Fig. 16 Twelve-layer $\text{TiO}_2/\text{SiO}_2(\text{HL})^6$ stack showing overlapping wet and dry scans.²¹

Fig. 17 Drive voltage versus drive current for various pumping speeds at the initial pressures of 2×10^{-4} and 3×10^{-4} Torr.²¹

This was studied previously by D.E. Morton. Complete details of the study are contained in Ref. 21.